



TECHNISCHE
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IAP-SEMINAR

EINLADUNG

Termin: **Dienstag, 23.3.2010 um 16:00 Uhr**
Ort: **Technische Universität Wien,
Institut für Angewandte Physik,
Seminarraum 134A, Turm B (gelbe Leitfarbe), 5. OG
1040 Wien, Wiedner Hauptstraße 8-10**

Vortragender: **Dr. Aimo Winkelmann**
Max-Planck-Institut für Mikrostrukturphysik, Halle (Saale)/D

Thema: **Diffraction of backscattered electrons at crystal surfaces**

Kurzfassung

Electron backscatter diffraction (EBSD) has developed into a valuable tool for the analysis of materials in the scanning electron microscope (SEM) [1]. Pronounced improvements in applications of the EBSD method can be expected if it is possible to gain access to a quantitative description of not only the total number of backscattered electrons, but also to the fine-scale angular variations observed as diffraction patterns of these electrons. A complete simulation of the observed intensities, however, is only possible by applying electron diffraction theories that can properly include the multiple (dynamical) scattering of keV electrons in crystals [2,3].

I will discuss the application of many-beam dynamical theory to the simulation of experimental diffraction patterns of backscattered electrons. By energy-resolved measurements, the correlation between the energy loss of the scattered electrons and their diffraction effects can be investigated. First experimental results of corresponding angle-resolved reflection electron energy loss measurements are presented [4]. It is shown that under certain conditions, inelastically backscattered electrons can show more pronounced diffraction effects than the elastic electrons.

1. A.J. Schwartz, M. Kumar, B.L. Adams, D. P. Field (Eds.), *Electron Backscatter Diffraction in Materials Science*, 2nd edition, Springer, Berlin, 2009
2. A. Winkelmann, C. Trager-Cowan, F. Sweeney, A. P. Day, P. Parbrook, *Ultramicroscopy* **107**, 414 (2007)
3. A. Winkelmann, *Ultramicroscopy* **108**, 1546 (2008)
4. M. R. Went, A. Winkelmann, M. Vos, *Ultramicroscopy* **109**, 1211 (2009)

*Alle interessierten Kolleginnen und Kollegen sind zu diesem Seminar
(45 min mit anschließender gemeinsamer Diskussion) herzlich eingeladen.*

*W. Werner e.h.
(Seminar-Chairperson)*

*H. Störi e.h.
(LVA-Leiter)*

